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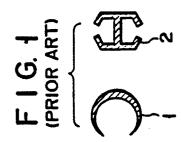
Date of deferred publication of the search report: 04.05.88 Bulletin 88/18 7 Applicant: E.I. DU PONT DE NEMOURS AND COMPANY
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6 Insulation displacement contact terminal.

An insulation displacement contact (IDC) terminal comprises an IDC slot defined by a pair of arms. A ridge is formed on the inner surface of each of the arms. In the IDC terminal of the particular construction, the arms are thinner in the edge portion than in the remaining structure, making it possible to reduce the total stress on to the arms.



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EUROPEAN SEARCH REPORT

EP 86 20 0743

	DOCUMENTS CONSI	DERED TO BE RELEVA	ANT	
Category		ndication, where appropriate,	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int. Cl. 4)
Х	FR-A-1 367 753 (EL * Page 2, left-hand 14-43; figures 1,5,	l column, lines	1-4	H 01 R 4/24
X	US-A-2 828 474 (B. * Column 3, line 67 18; figures 6-8 *		1-4	
х	FR-A-1 560 955 (WE * Page 4, lines 14-	STERN ELECTRIC CO.) 29; figure 3c *	1-3	
	,			H 01 R 4/24 H 01 R 13/00
	The present search report has b	een drawn up for all claims		
	Place of search	Date of completion of the search		Examiner
THE	HAGUE	29-01-1988		QUI J.J.
CATEGORY OF CITED DOCUMENTS X: particularly relevant if taken alone Y: particularly relevant if combined with another document of the same category A: technological background O: non-written disclosure P: intermediate document		NTS T: theory or pri E: earlier paten after the fili other D: document cit L: document cit	T: theory or principle underlying the invention E: earlier patent document, but published on, or after the filing date D: document cited in the application L: document cited for other reasons &: member of the same patent family, corresponding document	